## Amendments to the Claims

- 1-22. (Cancelled)
- 23. (New) An optical information recording medium capable of reproducing information using laser light, said optical information recording medium comprising:

a substrate:

a recording layer:

a reflective layer provided between said substrate and said recording layer;

a cover laver:

a reflective layer-side dielectric layer disposed between said reflective layer and said recording layer; and

an incident light-side dielectric layer disposed between said recording layer and said cover layer,

wherein said reflective layer is formed as a film directly on said substrate, and is an aluminum alloy containing at least 1 atom percent and no more than 5 atom percent nickel.

- 24. (New) The optical information recording medium according to Claim 23, wherein a thickness of said reflective layer is at least 20 nm and no more than 300 nm.
- (New) The optical information recording medium according to Claim 23, wherein said reflective layer-side dielectric layer contains sulfur.
- 26. (New) The optical information recording medium according to Claim 23, wherein a main component of said reflective layer-side dielectric layer is ZnS or an oxide, main components of said recording layer are germanium and antimony, or germanium, bismuth, and tellurium, and a main component of said incident light-side dielectric layer is ZnS or an oxide.
- 27. (New) The optical information recording medium according to Claim 23, wherein a

thickness of said reflective layer-side dielectric layer is at least 15 nm and no more than 50 nm, a thickness of said recording layer is at least 5 nm and no more than 15 nm, and a thickness of said incident light-side dielectric layer is at least 10 nm and no more than 100 nm.

- 28. (New) The optical information recording medium according to Claim 23, wherein said reflective layer-side dielectric layer is in contact with said reflective layer.
- (New) A method for manufacturing an optical information recording medium comprising:

forming a reflective layer on a substrate;

forming a recording layer on the substrate; and

forming a cover layer, a reflective layer-side dielectric layer disposed between the reflective layer and the recording layer, and an incident light-side dielectric layer disposed between the recording layer and the cover layer,

wherein the reflective layer is formed as a film directly on the substrate and said forming of the reflective layer includes using a sputtering target comprising an aluminum alloy containing at least 1 atom percent and no more than 5 atom percent nickel, and

wherein the reflective layer is formed between the substrate and the recording layer.